

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S41	170	moslehi.inv.	US-PGPUB; USPAT	OR	ON	2005/03/12 13:41
S40	1	S36 and S32	US-PGPUB; USPAT	OR	ON	2005/03/12 13:41
S39	1	S32 and S36	US-PGPUB; USPAT	OR	ON	2005/03/12 13:04
S38	27	S36 and S37	US-PGPUB; USPAT	OR	ON	2005/03/12 13:04
S32	46	subphotolithographic "sub-photolithographic" "sub photo lithographic"	US-PGPUB; USPAT	OR	ON	2005/03/12 13:04
S37	27	S36 and critical with dimension	US-PGPUB; USPAT	OR	ON	2005/03/12 13:02
S36	236	(438/947).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/03/12 13:02
S31	100	"etch/dep" or "etch/deposition"	US-PGPUB; USPAT	OR	ON	2005/03/12 13:01
S35	29	S32 and "438".clas.	US-PGPUB; USPAT	OR	ON	2005/03/12 12:55
S34	45	S31 and "438".clas.	US-PGPUB; USPAT	OR	ON	2005/03/12 12:55
S33	0	S31 and S32	US-PGPUB; USPAT	OR	ON	2005/03/12 12:54
S30	10	"etch/dep"	US-PGPUB; USPAT	OR	ON	2005/03/12 12:52
S1	237	gambino.inv.	US-PGPUB; USPAT	OR	ON	2005/03/12 12:52
S29	84	((438/694) or (438/696) or (438/700) or (438/720) or (438/735) or (438/736)).CCLS.) and "photoresist" with spacer	US-PGPUB; USPAT	OR	ON	2005/03/09 09:02
S19	76	((438/694) or (438/696) or (438/700) or (438/720) or (438/735) or (438/736)).CCLS.) and "photoresist" with spacer	US-PGPUB; USPAT	OR	ON	2005/03/09 09:02
S28	22	plasma with (ald or ale or "atomic layer deposition" or "atomic layer depositing") with ((silicon adj nitride) or "si.sub.3n.sub.4" or "si. sub.xn.sub.y" or sin or "sin.sub.x")	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/08 13:53
S27	12426	plasma with ((silicon adj nitride) or "si.sub.3n.sub.4" or "si.sub.xn. sub.y" or sin or "sin.sub.x")	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/08 13:52

S26	6	("20030013320" "4699861" "4844719" "6284646" "6391769" "6466403").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/08 13:51
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